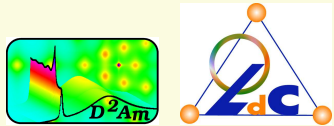


A multi elements assembly for X-ray synchrotron  
radiation measurement

**XPAD : pixels detector for material sciences.**



D2AM/CRG-ESRF  
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Grenoble

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seminar at ANKA facilities, jan. 31th, 2005.

**ISS** Institute for Synchrotron Radiation

# Summary.

- Detectors & material sciences scattering 3
- XPAD project 6
- Dynamical range, resolution, ... 8
- XPAD2 calibration and dispersion 11
- Kinetics potentiality 14
- Powder diffraction application 15
- SAXS application 18
- from XPAD2 to XPAD3 20

# Detectors & material sciences scattering

**Imaging** : → X-ray microscopy, X-ray topography, X-ray radiography

**Spectroscopy** : chemical composition (XAS), short order range (EXAFS)

**Scattering** by beam →  $I(Q) \propto F^2(\rho)_e$

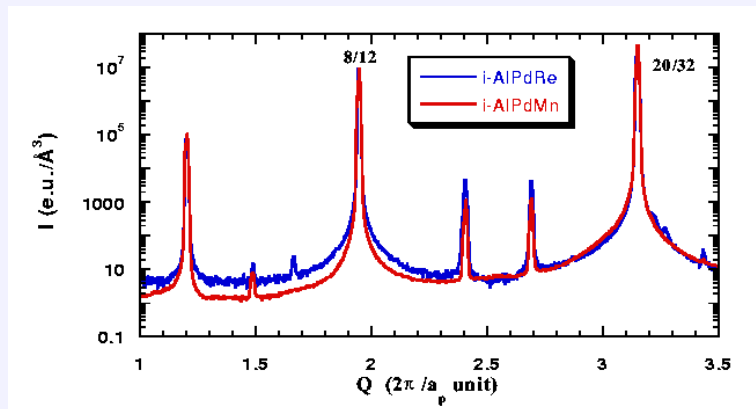
## Intensity range in scattering experiments

|                      |     |                |                                       |
|----------------------|-----|----------------|---------------------------------------|
| $1 \rightarrow 10^4$ | 13b | mean structure | chemistry (biocrystallography)        |
| $1 \rightarrow 10^6$ | 20b | ordering       | correlation, incommensurate           |
| $1 \rightarrow 10^9$ | 30b | SAXS           | $\mu m$ objects interaction, polymers |

- Synchrotron → current flux on sample :  $10^{11} - 10^{14} \nu/s$
- Spot size at sample or detector position :  $1 \times 5 \rightarrow 0.05 \times 0.10 \text{ mm}^2$
- Counting rate :  $10^9 \nu/s$  within  $10^{-2} \text{ mm}^2$
- Resolution : angular  $10^{-3} \text{ }^\circ \rightarrow 100 \mu m$  at  $0.5 \text{ m} \approx 0.01 \text{ }^\circ$

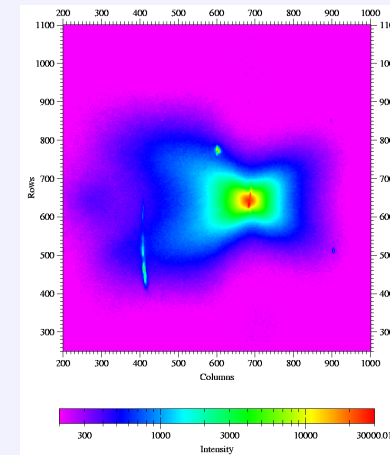
# On BM2/ESRF beamlines in 2004

Very demanding experiments use slits and photomultipliers to reach the required quality.



Diffuse scattering in icosahedral quasi-crystals : 7 orders of magnitude are necessary to measure this signal. Dynamic extended by filters, time consuming mapping

In structural works, CCD cameras with indirect photon detection are commonly used.



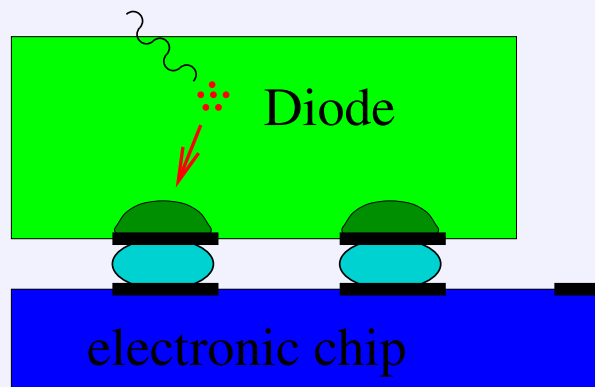
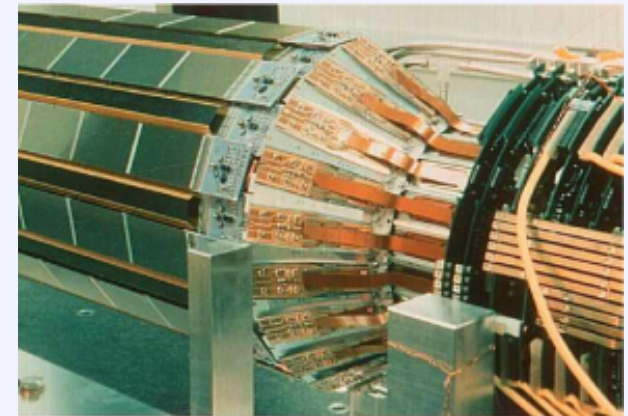
Complex shape of the diffusion around Bragg peak obtained by adding 10 (1000) frames. Out of peak to avoid blooming effects

Data from M. de Boissieu, see Phil. Mag. Let. (2001) 81, 273-283 and (2003) 83, 1-29

# D2AM-CRG/ESRF detector requirement

|                 |   |  |
|-----------------|---|--|
| dynamic range   | $> 10^9 \text{ count/pixel}$              | $\Rightarrow 32 \text{ bits architecture}$   |
| saturation rate | $> 10^7 \nu/s/pixel$                      | $\Rightarrow \text{noise} < 0.1 \nu/s/pixel$ |
| energy range    | $5 \rightarrow 25 \text{ keV}$            | from dynamic range                           |
| pixel size      | $250 \times 400 \mu\text{m}^2$            | mean spot size in 1995                       |
| exposure time   | $1 \text{ ms} \rightarrow 1000 \text{ s}$ | kinetics potentiality                        |

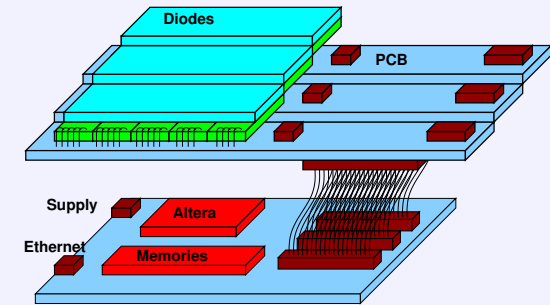
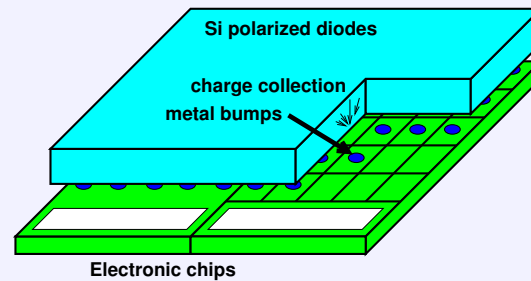
High energy physics experiments lead to built detector like Delphi at CERN which uses the potentiabilities offered by microelectronics and direct photon conversion in silicon.



The silicium thickness  $300 \mu\text{m}$  and the pixel sizes  $330 \times 330 \mu\text{m}^2$  were convenient to our beamline requirements leading to the project of building a new X-ray detector starting from the knowledge of the Delphi detector peoples.

# The XPAD project

- Absorbed photons
- electron clouds
- charge migration
- electron bunches
- pixel threshold
- pixel counters
- on-board memories
- ethernet data

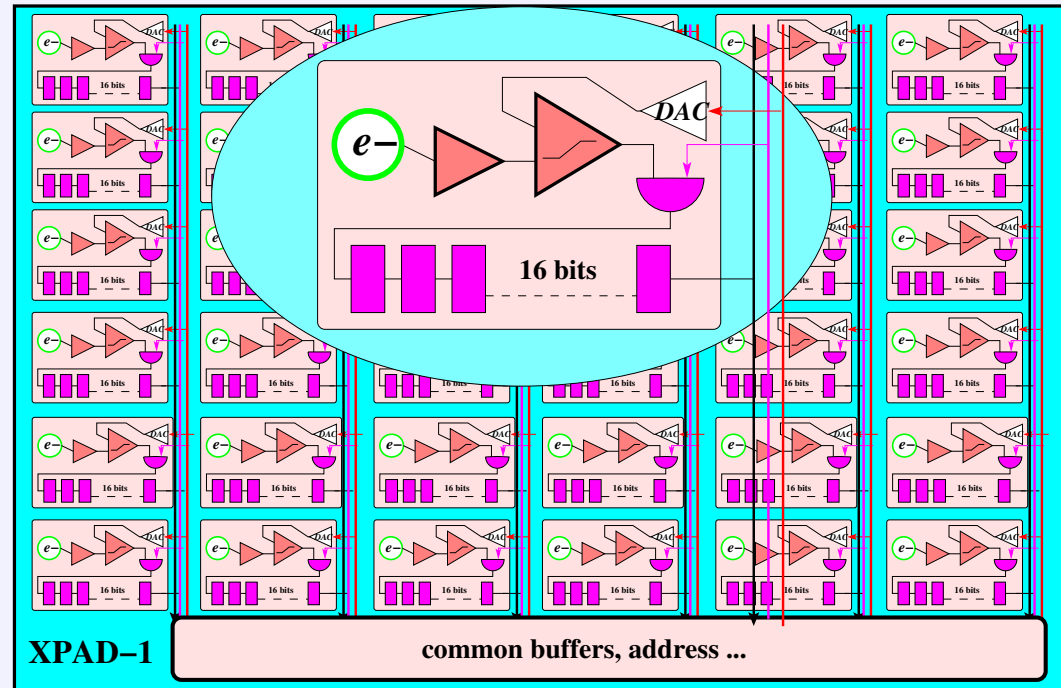


Diodes :

- high resistivity Si

Chips :

- AMS CMOS  $0.8 \mu m$
- $24 \times 25$  pixel/chip



Boudet *et al.*, NIM A510 (2003) 41-44,

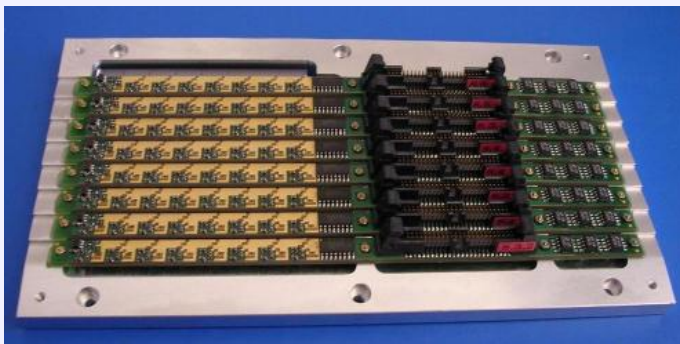
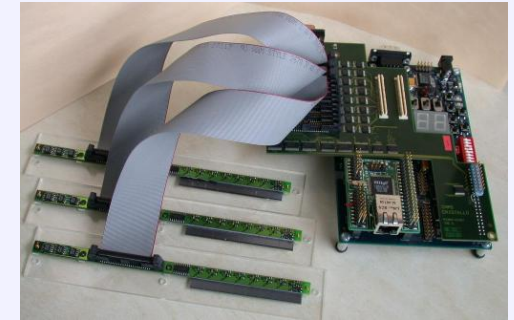
Berar *et al.*, J. Appl. Cryst. 35 (2002) 471-476

# XPAD2 detector : 8 modules $\times$ 8chips

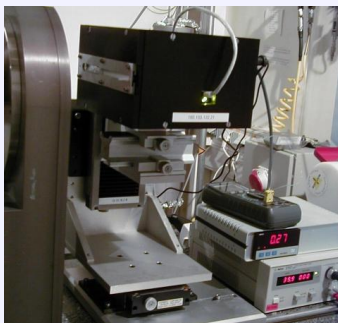
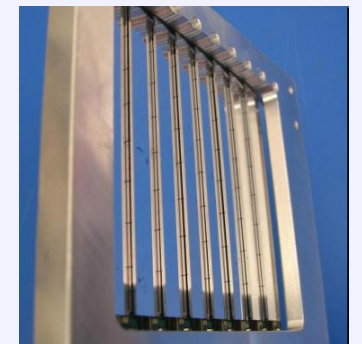
New diodes of  $500\mu\text{m}$  Si thick  $\rightarrow$  efficiency 78 % @15keV, 21% @25keV



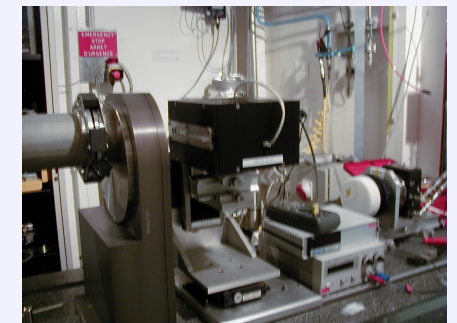
Diode  $\Rightarrow$  8 chips of  $24 \times 25$  pixels  
PCB card : drivers and regulators.  
Modules  $\Rightarrow$  acquisition card  
Altera Nios kit + ethernet



Tiled as close as possible  
 $\rightarrow$  reduce shading, dead zones.  
Metallic holder  $\rightarrow$  few  $\mu\text{m}$ .  
Size :  $200 \times 192$  pixels  
Surface  $\approx 68 \times 68\text{mm}^2$ .



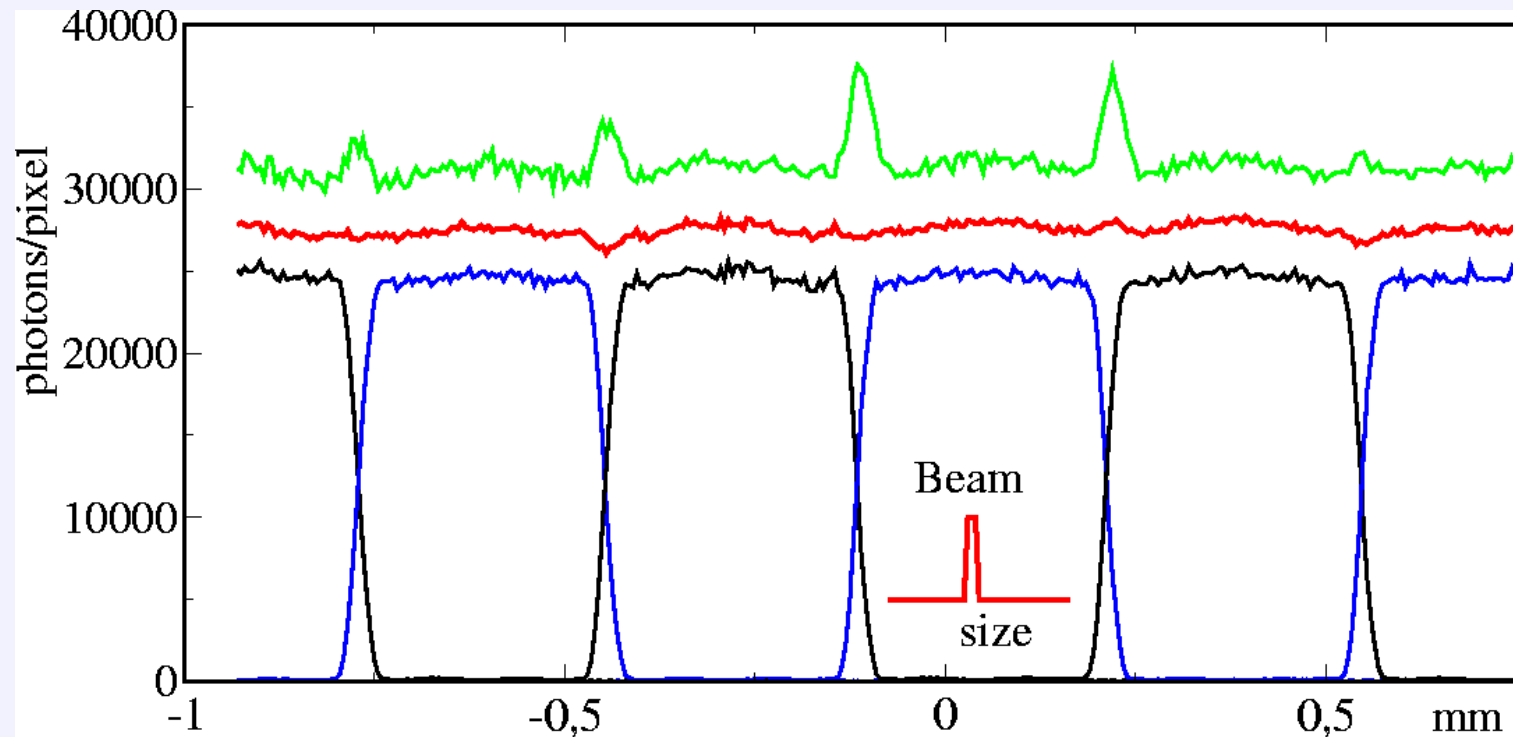
Interface software  
developed using LabWindows/CVI  
application software moves to Linux.  
XPAD prototype at SAXS station.



# Spatial resolution

As the diode is common to pixels belonging to the same chip, some charge sharing may occur between adjacent pixels.

Measurements show that the charge sharing occurs on  $\approx 60 \mu\text{m}$ .

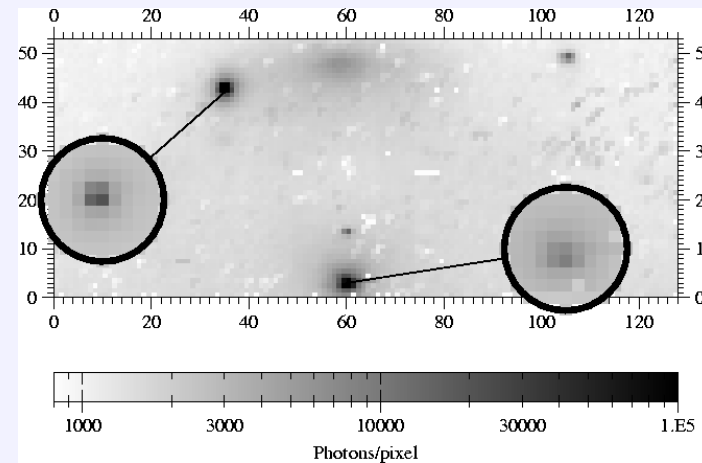
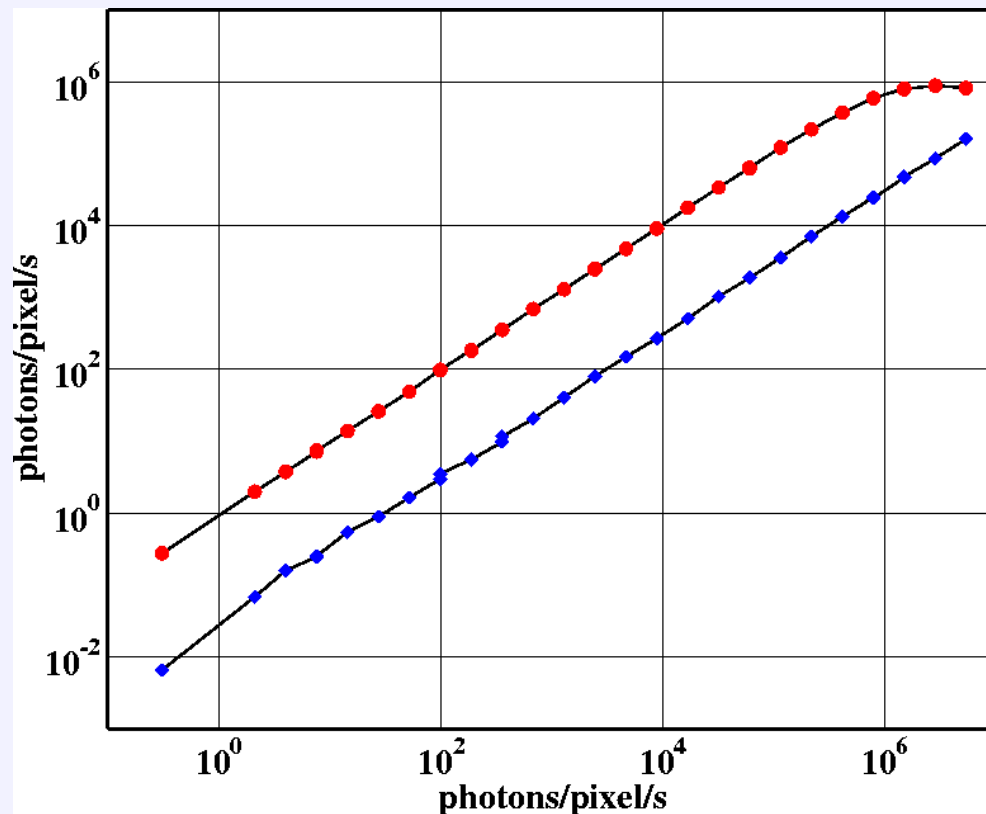


A flat field can be obtained when energies edge is perfectly adjusted in each pixel (red). In case of too low edges, this share sharing create some over-counting at pixel borders (green).

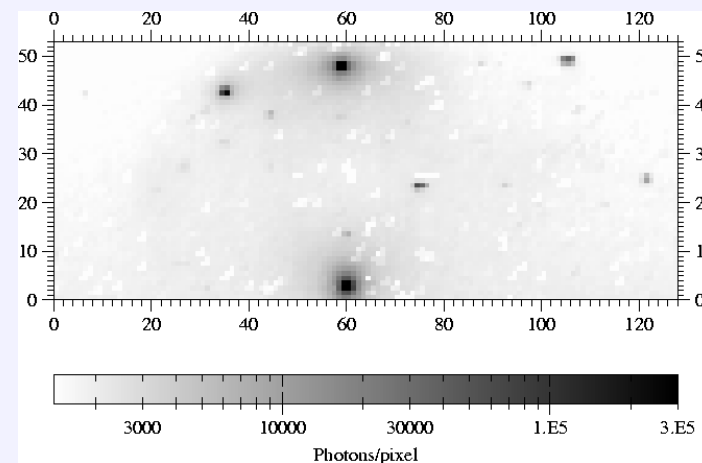


# Dynamical range (XPAD1)

The curves show the counts in two adjacent pixels as a function of the incoming flux on the more exposed pixel using XPAD chips.

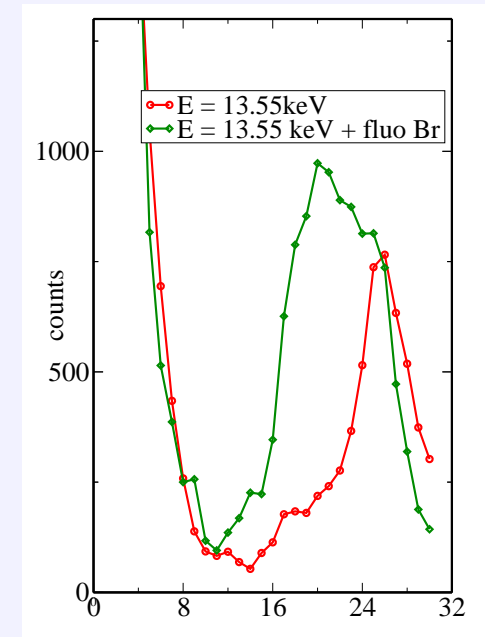
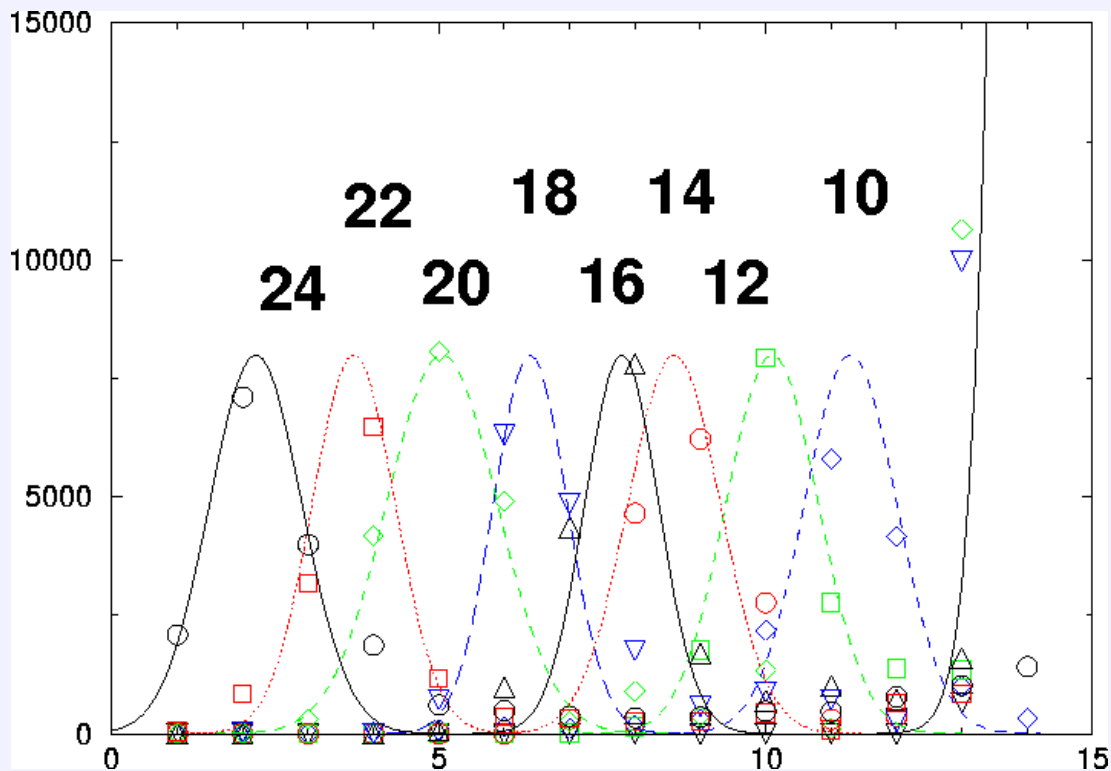


Diffusion (above) of a CdYb icosahedral quasicrystal and associated rotation image (below).



# Energy resolution

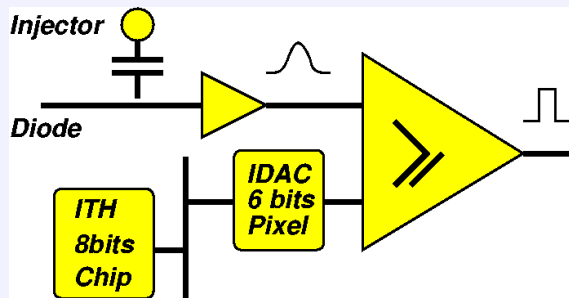
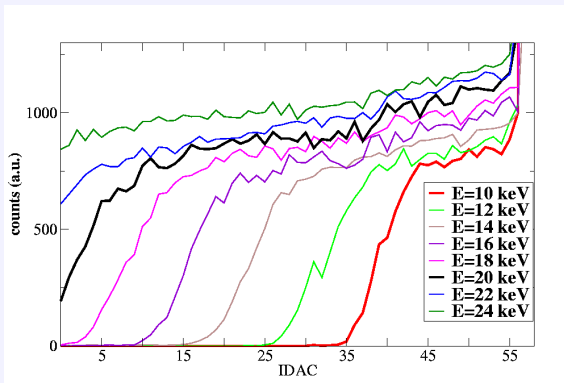
The conversion of incoming photons in silicon leads to a charge proportional to the incoming energy. The XPAD chip energy resolution is near  $1\text{ keV}$ .



Measured counts as a function of the threshold for the diffusion in of a Br solution on both sides of Br absorption edge.

Pixel threshold register : 4 bits (XPAD1)  $\rightarrow$  6 bits (XPAD2)

# XPAD2 calibration and dispersion (1)



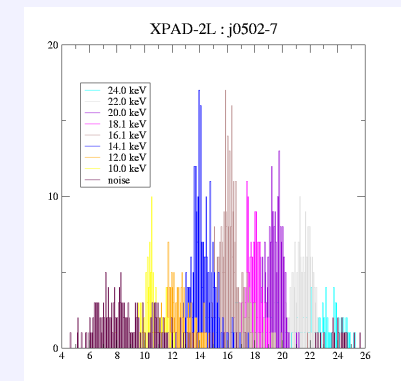
- *beam*  $E_x$  : monochromatic flat scattering (amorphous), noisy, time expensive
- *injection*  $E_{inj}$  : simulate the beam, quick and easy but need calibration
- Each pixel is described by :  $C, \alpha, \beta, E_{inj}(noise)$   

$$E_x = C E_{inj} = \alpha(I_{th}) + \beta(I_{dac})$$

$$E_x(noise) = C E_{inj}(noise)$$
- $\approx 4 \cdot 10^4$  pixels  $\Rightarrow$  automatic configuration/calibration procedure.

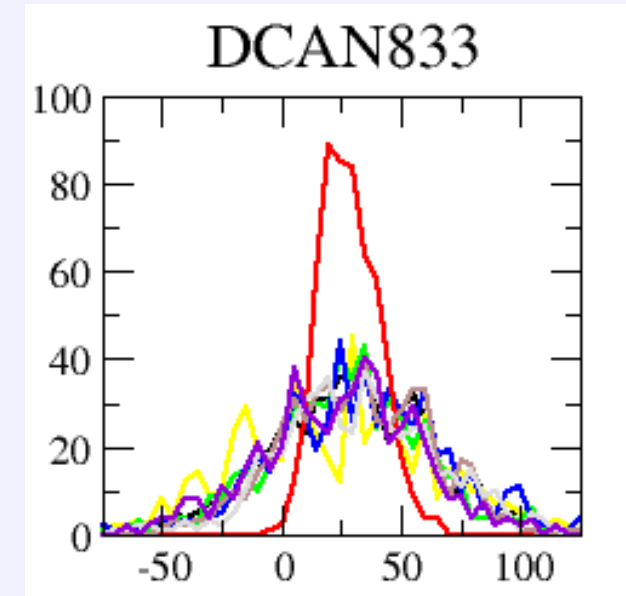
Knowing then these characteristics :

the setup of each chip at a given energy  $E$  can be defined as the value of the chip common threshold level  $I_{th}$  for which most of the pixels can be fine tune,  $I_{dac} \in [0, 63]$ .



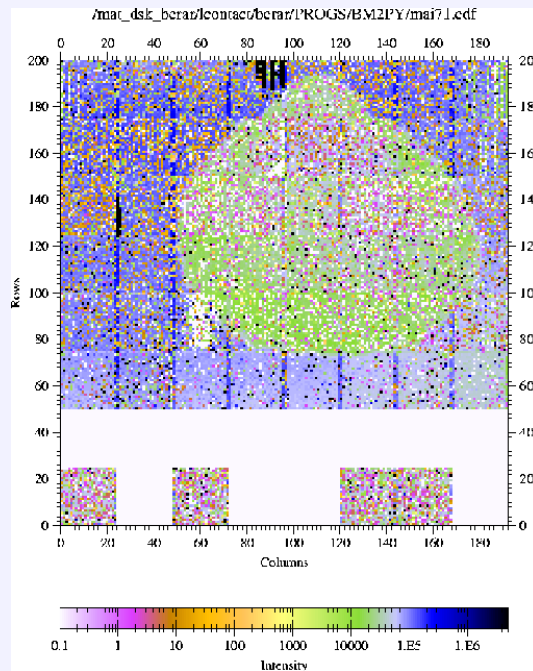
# XPAD2 calibration and dispersion (2)

- XPAD2 initial threshold dispersion  $60 e^-$   
⇒ pixels not tuned  $< 3\%$
- manufacturing problems :  
leakage in bumping process  
⇒ new foundry using the same masks
- threshold dispersion increase strongly  
 $\approx 120 e^-$  on most chips  
⇒ pixels not tuned  $< 15\%$

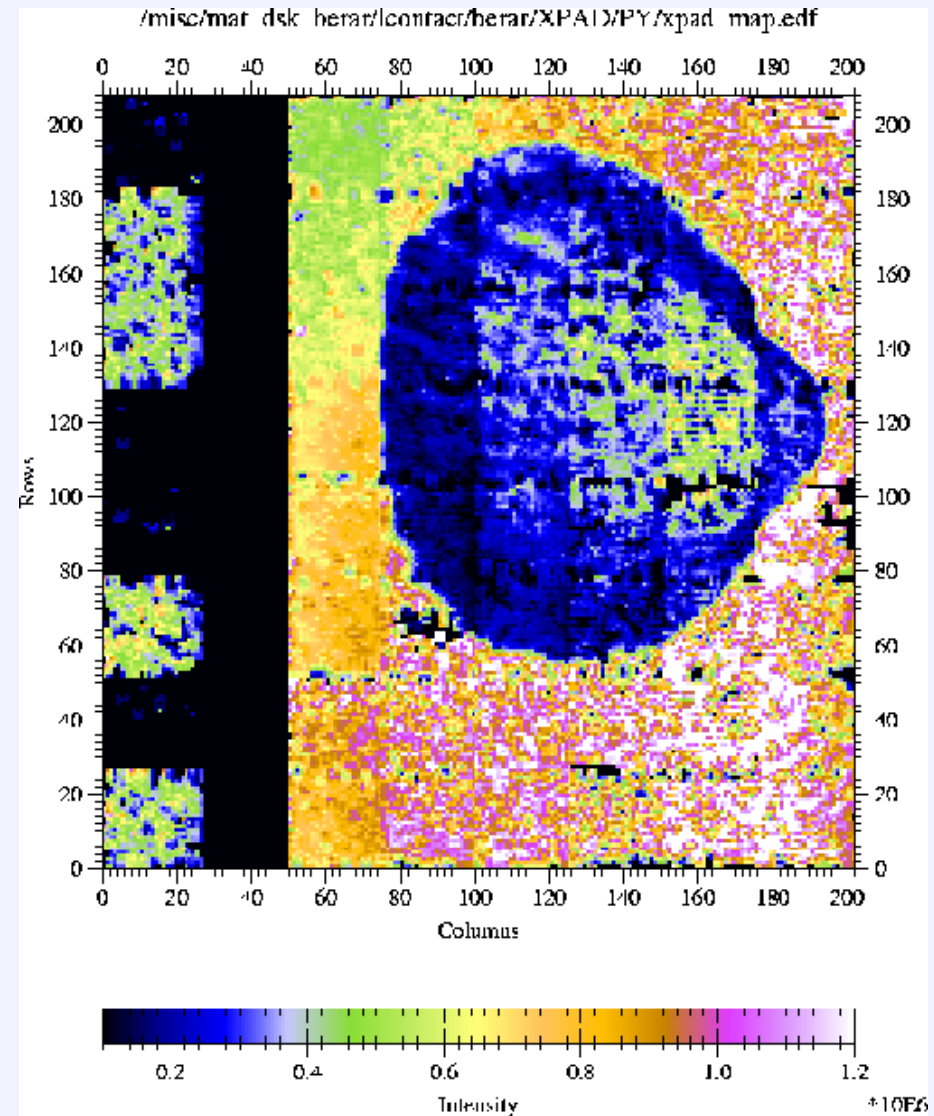


However, even if all the pixels are not perfectly set, the XPAD2 detector appears as a usefull tool for recording new data in SAXS and diffraction on a synchrotron beamline in the range 15 - 25 keV.

# XPAD2 calibration and dispersion (3)



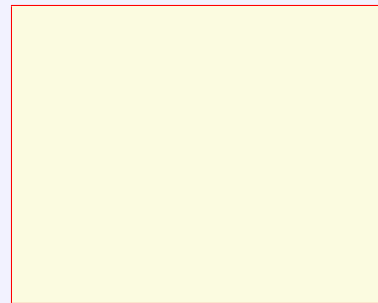
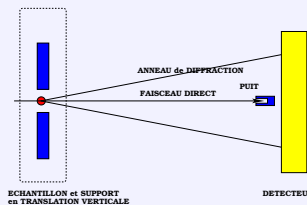
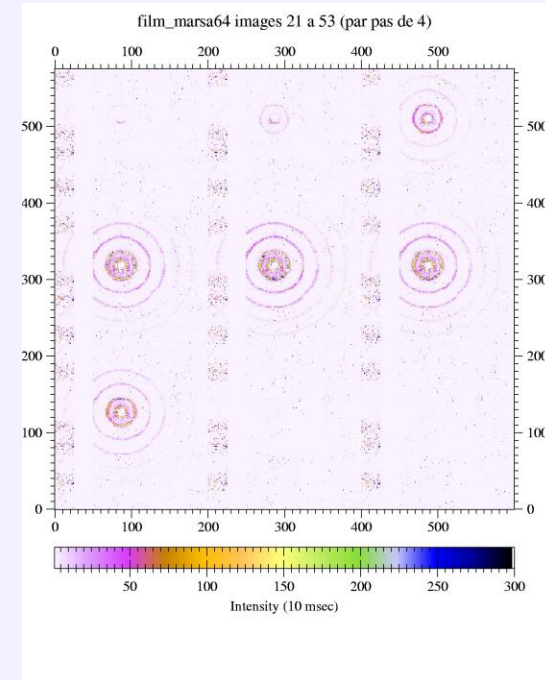
Correcting raw image from surface,... and merging 2/4 images lead to reasonable one.



# Kinetics potentiality of XPAD2

Whole electronic designed to allow kinetics studies (ms range)

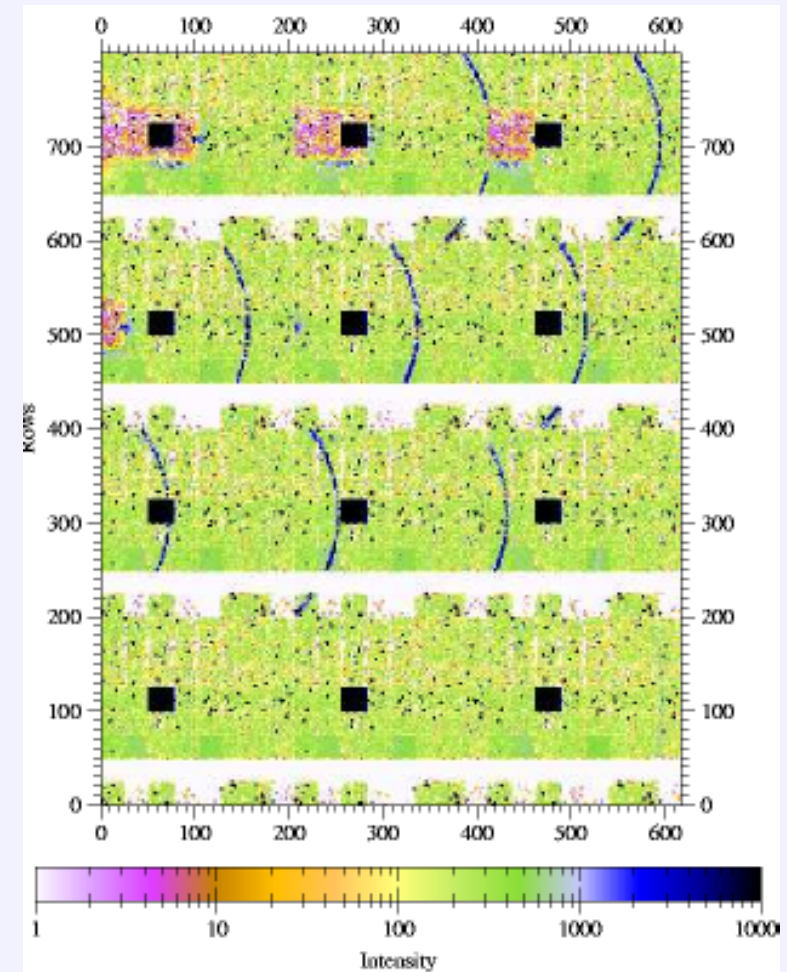
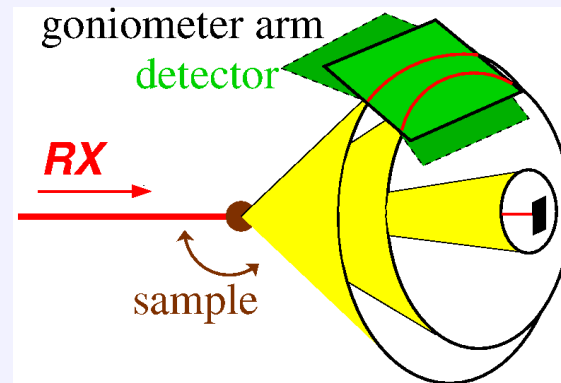
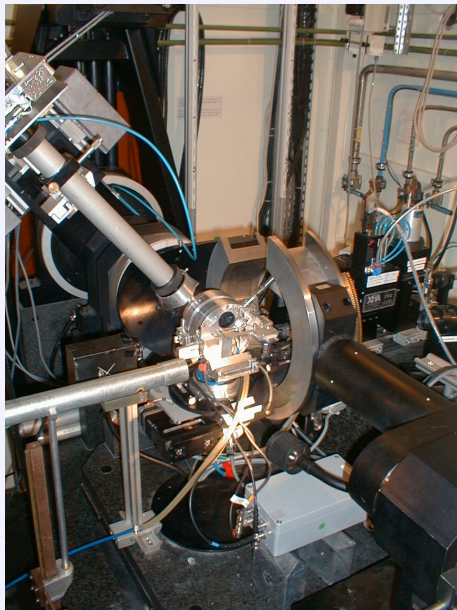
- chips register 16bits + overflow
- on-board memories 32 bits
- exposure time :  $1ms \rightarrow 8300s$
- dead time for reading :
  - whole image  $2ms$
  - overflow  $16\mu s$  each  $10ms$
- on-board storage :
  - 423 images  $< 10ms$
  - 233 images  $\geq 10ms$



Images of 10 ms each taken off a 2s **movies** showing diffraction while the sample crosses the beam at D2AM SAXS camera.

# Powder diffraction application (1)

- Diffraction along cones
- Data redundancy with 2D detector
- $60^\circ$  collected at high resolution
- angular aperture  $4^\circ$  at  $1m$



Pipes and slits  $\rightarrow$  2d-detector.

First raw images with beam stop and one Bragg line.

# Powder diffraction application (2)

- Complex pattern of a Zeolite
- Reconstructed Debye-Scherrer film  $\rightarrow$

Resulting  $Y$  counts on pixel  $p$  :

$$Y_p = N_p^{-1} \sum f_q y_{q,i}$$

$y_{q,i}$  counts on image  $i$  of pixel  $q$

$f_q$  flatfield of pixel  $q$  :

Pixel :  $q$  in image  $i \rightarrow p$  in merged image

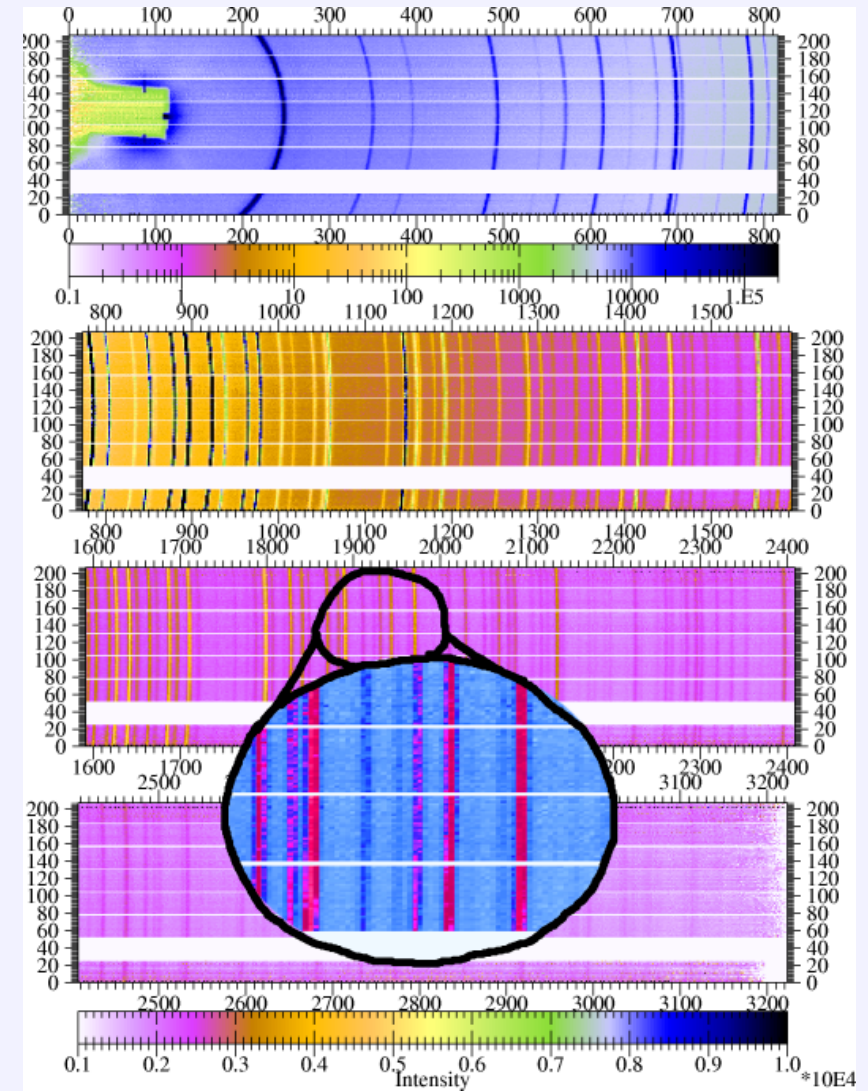
$$q = q(p, i)$$

Minimisation of :

$$\sum_p (Y_p - N_p^{-1} \sum_i f_q y_{q,i})^2$$

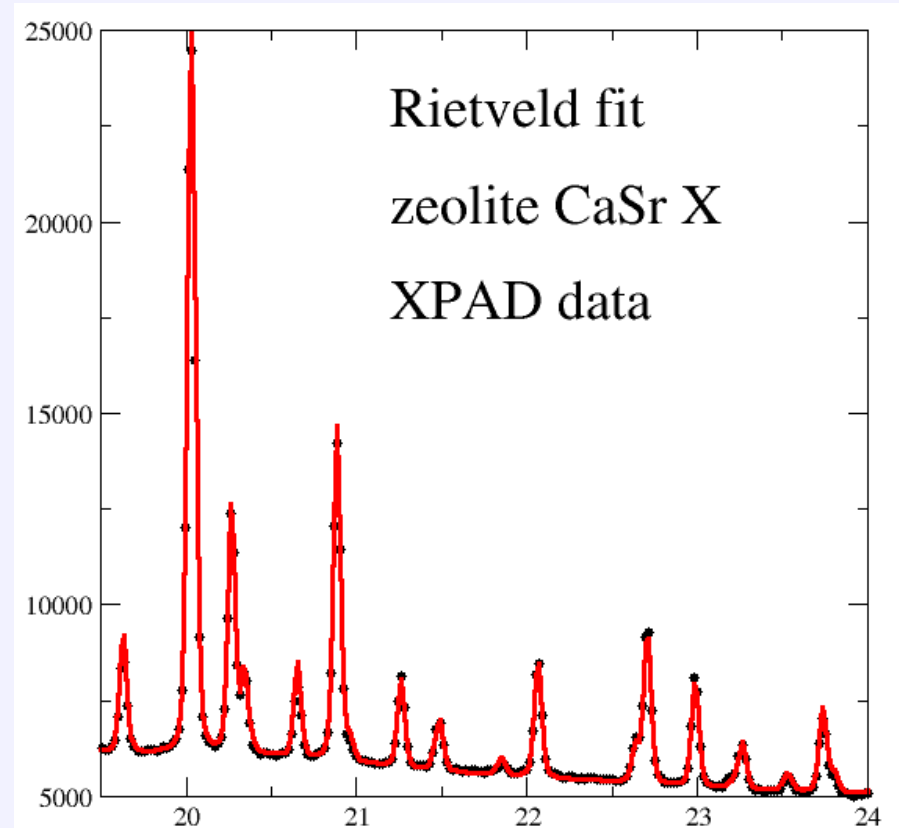
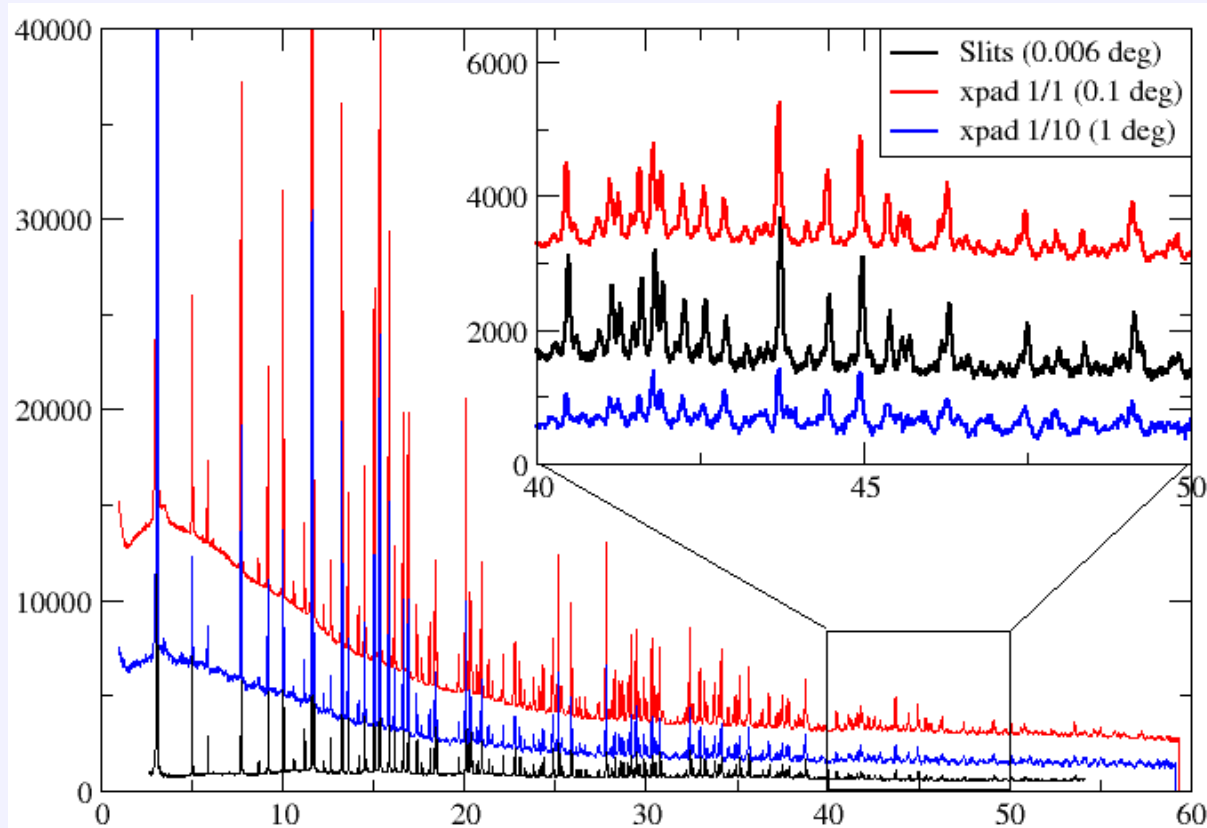
Powder lines :  $Y_{p \in Ring} \rightarrow Y_{Ring}$

$$\sum_{Ring} (Y_{Ring} - N_{Ring}^{-1} \sum_{p \in Ring} \sum_i f_q y_{q,i})^2$$





# Powder diffraction application (3)



Rietveld method :  $R_{wp}=8.8\%$

$R_{exp}=4.1\%$  and  $R_{bragg}=4.4\%$

Atomic parameters same as conventional

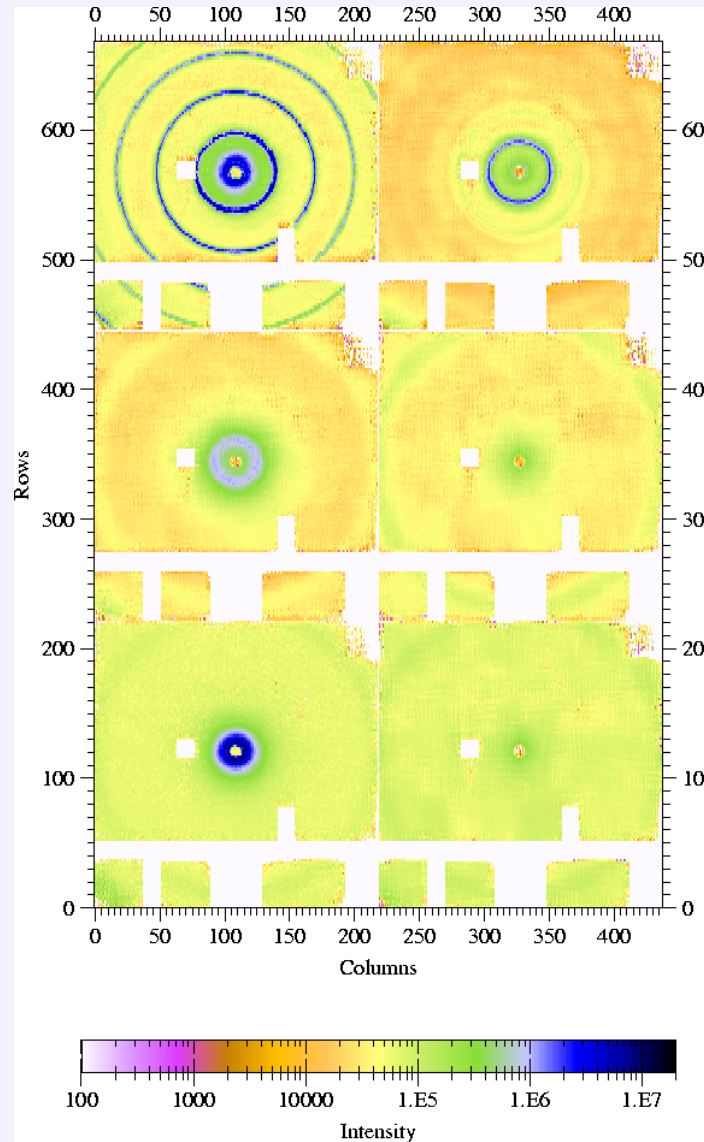
Whole experiment time  $\rightarrow 1/20$ .

Data recorded in 1/200 time will lead to very similar results but extracting procedure needs improvements.

# SAXS application (1)

Scattering of some samples recorded at BM2-SAXS camera using XPAD detector at 20 *keV*.

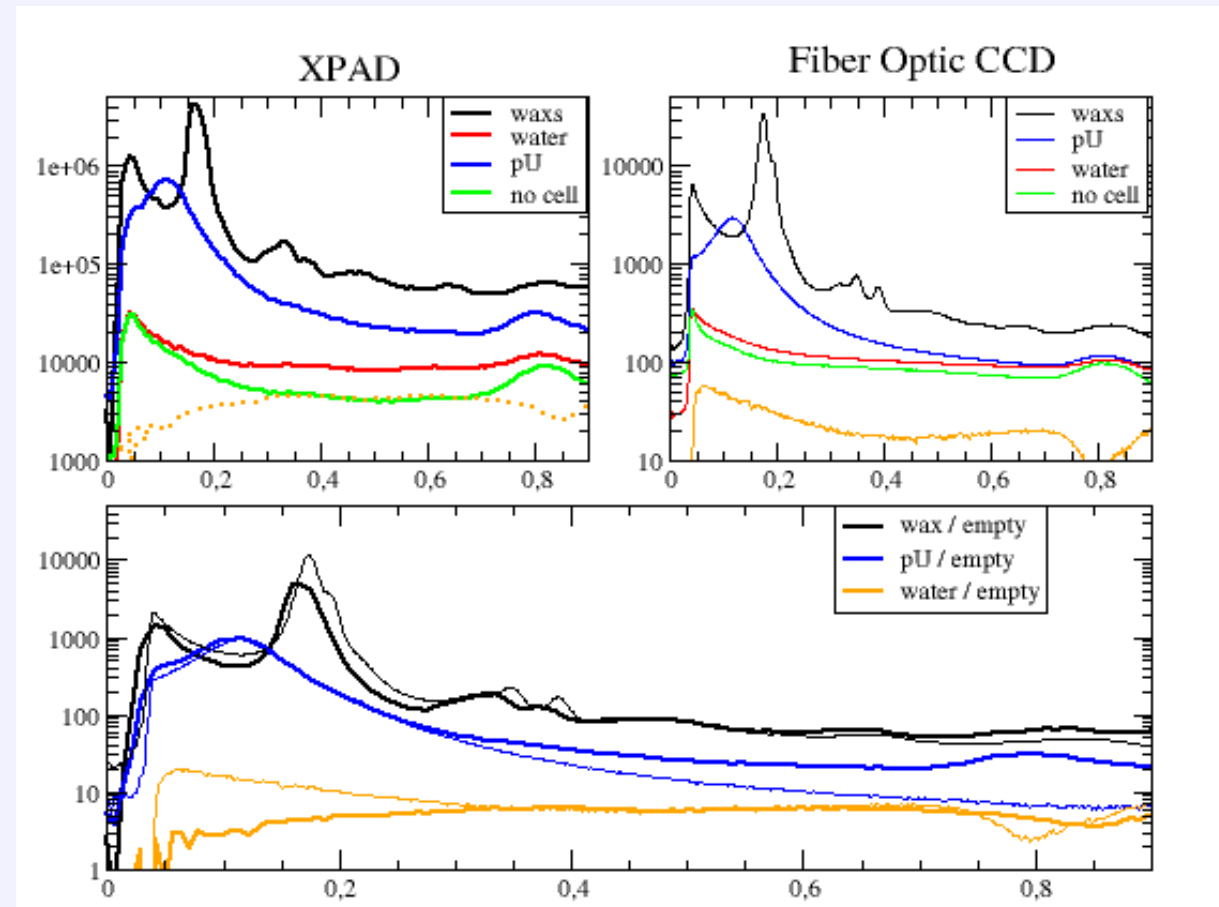
- Ag Behenate
- Bee waxes
- Polyurethan
- Empty cell
- Teflon
- Water (5mm)



# SAXS application (2)

Data have been compared with FOB CCD\* ones using the same setting.

The low noise achieved with the XPAD detector allows to improve the measurement of weak scatterer like water : the signal observed without sample is really lower with XPAD than with the CCD (fluorescence, PSF tails ...)



\* PI-SCX-1300, Roper Scientific (EEG 1340x1300, 50 $\mu$ m pixel size, dark corrected)

# from XPAD2 to XPAD3

- Improving XPAD2 chips in AMS-CMOS  $0.8 \mu m$  technology ?
- Or design a new XPAD3 using  $0.25 \mu m$  technology ?

|                 | XPAD2                               | XPAD3                                | comments                |
|-----------------|-------------------------------------|--------------------------------------|-------------------------|
| polarization    | both                                | $e^+$                                | dedicated to Si diodes  |
| pixel size      | $330 \mu m$                         | $125 \mu m$                          |                         |
| chip size       | $8 \times 10 mm^2$                  | $10 \times 15 mm^2$                  | → reduce tiling         |
| counting rate   | $2 \cdot 10^6 ph/s$                 | $2 \cdot 10^5 ph/s$                  | similar by surface unit |
| energy range    | (5) $15 \rightarrow 25 keV$         | $7 \rightarrow 25 keV$               | analog chain modified   |
| pixels/chip     | $24 \times 25 = 600$                | $80 \times 120 \approx 1 \cdot 10^4$ |                         |
| pixels/module   | $8 \times 600 \approx 5 \cdot 10^3$ | $\approx 1 \cdot 10^5$               |                         |
| pixels/detector | $\approx 4 \cdot 10^4$              | $\approx 5 \cdot 10^5$               |                         |
| geometries      | $8 \times 8$ or $2 \times 5$        | $8 \times 8$ and ?                   |                         |

Prototype expected for spring 2006.